

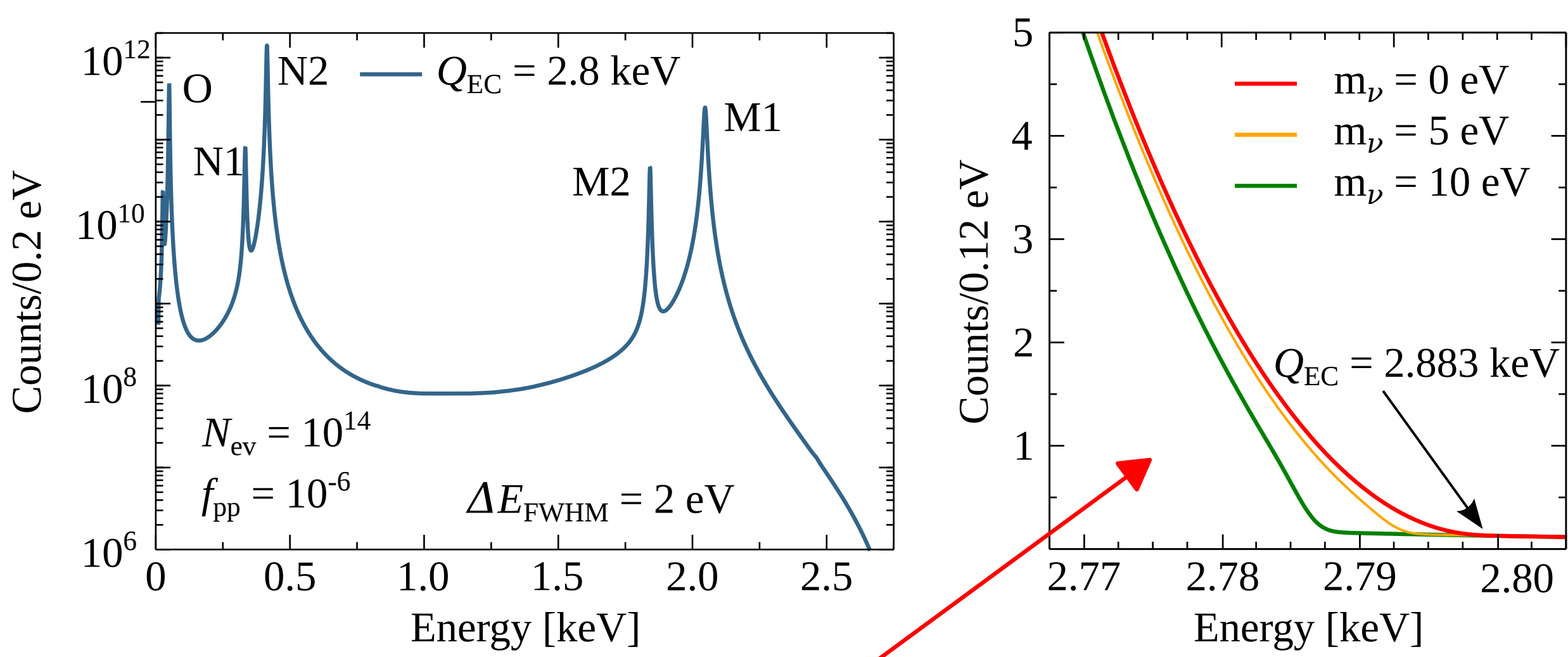
Overview

HOLMES is an experiment with the aim to directly measure the neutrino mass. HOLMES will perform a calorimetric measurement of the energy released in the Electron Capture decay of the artificial isotope ^{163}Ho . The most suitable detectors for this type of measurement are low temperature thermal detectors. HOLMES will deploy 1000 detectors of low temperature microcalorimeters with implanted ^{163}Ho nuclei with the aim to extract information on neutrino mass with a sensitivity below 2 eV. As soon as the embedding technique will be optimized the first sub-arrays will provide useful data about the EC decay of ^{163}Ho together with a first limit on neutrino mass.

B. Alpert et al. Eur. Phys. J. C75 (2015) 112

^{163}Ho Electron Capture Decay

- Electron capture from shell $\geq M1 \rightarrow ^{163}\text{Ho} + e^- \rightarrow ^{163}\text{Dy}^* + \nu_e(E_c)$
A. De Rujula and M. Lusignoli, Phys. Lett. B 118 (1982) 429.
- Calorimetric measurement of Dy atomic de-excitations \Rightarrow measurement of the entire energy released except the ν energy;
- Rate at end-point and ν mass sensitivity depend on Q_{EC}
 \Rightarrow Measured with Penning trap: $Q_{EC} = 2.833$ keV; S. Eliseev et al, Phys. Rev. Lett. 115 (2015) 062501
- High specific activity $\Rightarrow \tau_{1/2} = 4570$ years



Statistical sensitivity $\Sigma(m_\nu)$ from MC simulations

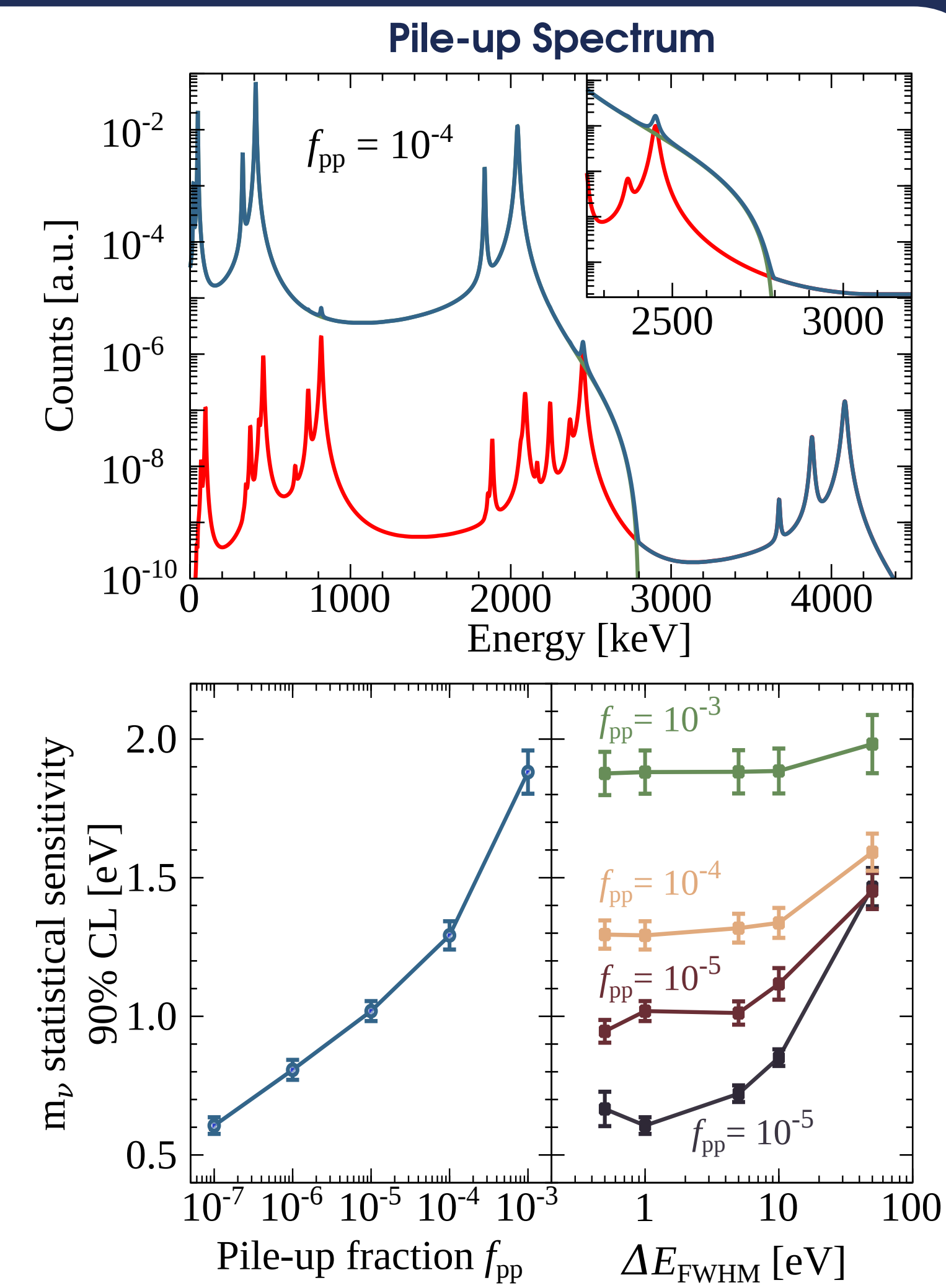
A. Nucciotti, Eur. Phys. J. C 74 (2014) 3161

- Strong on statistic
 $N_{ev} = A_{EC} \cdot N_{det} \cdot T_M \Rightarrow \Sigma(m_\nu) \propto N_{ev}^{-1/4}$
Measurement live time
Number of detectors
Single pixel activity
- Strong on rise time pile-up
Probability $\Rightarrow f_{pp} \approx A_{EC} \cdot \tau_r$
Detector time resolution
- Weak on energy resolution ΔE

HOLMES target

- Microcalorimeters base on Transition Edge Sensors with ^{163}Ho implanted Au absorber
- Pixel activity of $A_{EC} \sim 300$ Bq/det
- Energy resolution: O(eV)
- Time resolution : $\tau_r \sim 1 \mu\text{s}$
- 1000 channels for 3×10^{13} events collected in $T_M = 3$ years

Expected Sensitivity $m_\nu \leq 2$ eV



^{163}Ho production and embedding

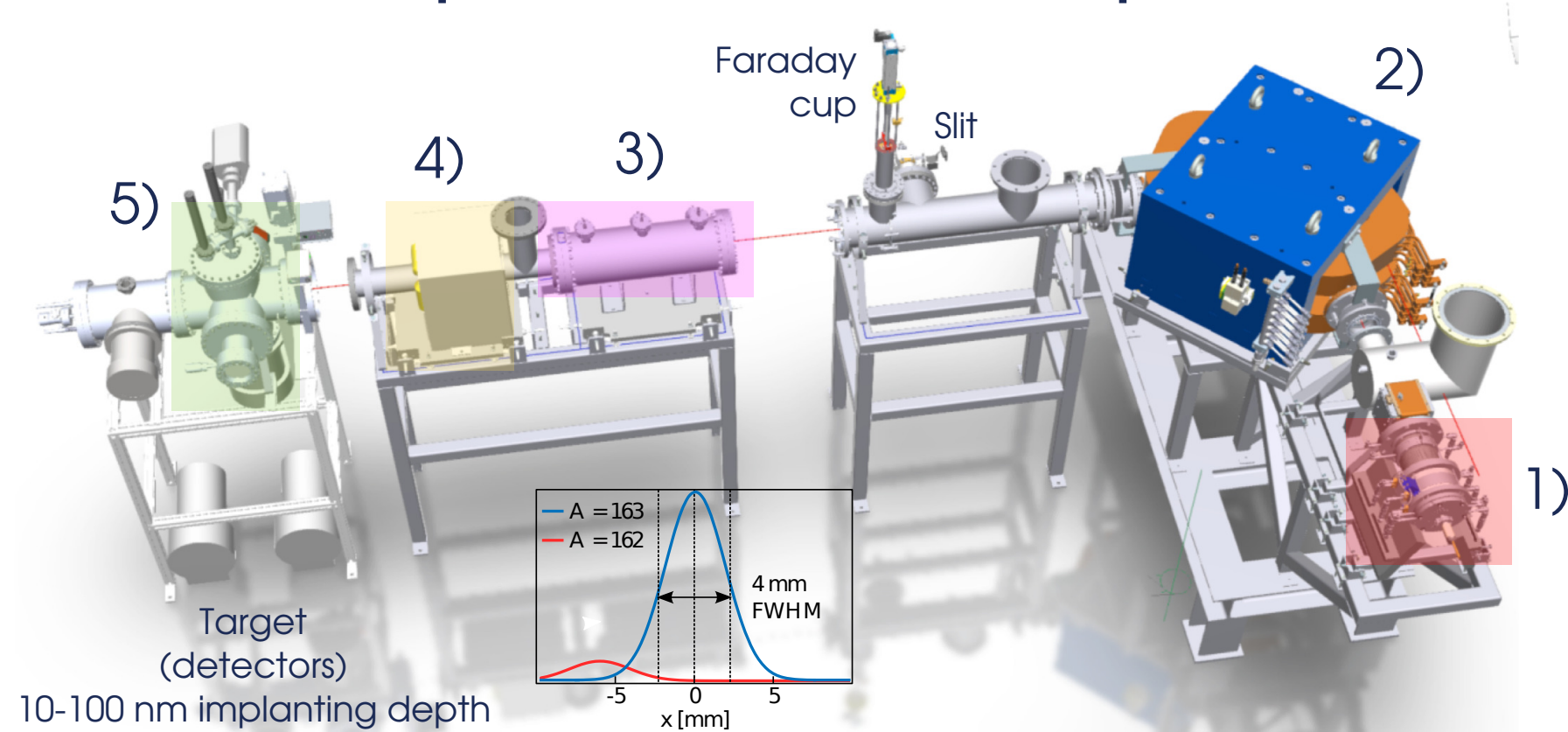
Production by neutron activation of enriched ^{162}Er

Er 162 0.139 11.4	Er 163 75 m 1.601	Er 164 1.601 10.3 h	Er 165 10.3 h 1.601	Er 166 33.503 23 s	Er 167 22.869 15.5 s
Ho 161 6.7 a 2.3 s	Ho 162 69 m 1.601	Ho 163 11.4 10.3 h	Ho 164 10.3 h 1.601	Ho 165 10.3 h 1.601	Ho 166 100 25.60 h



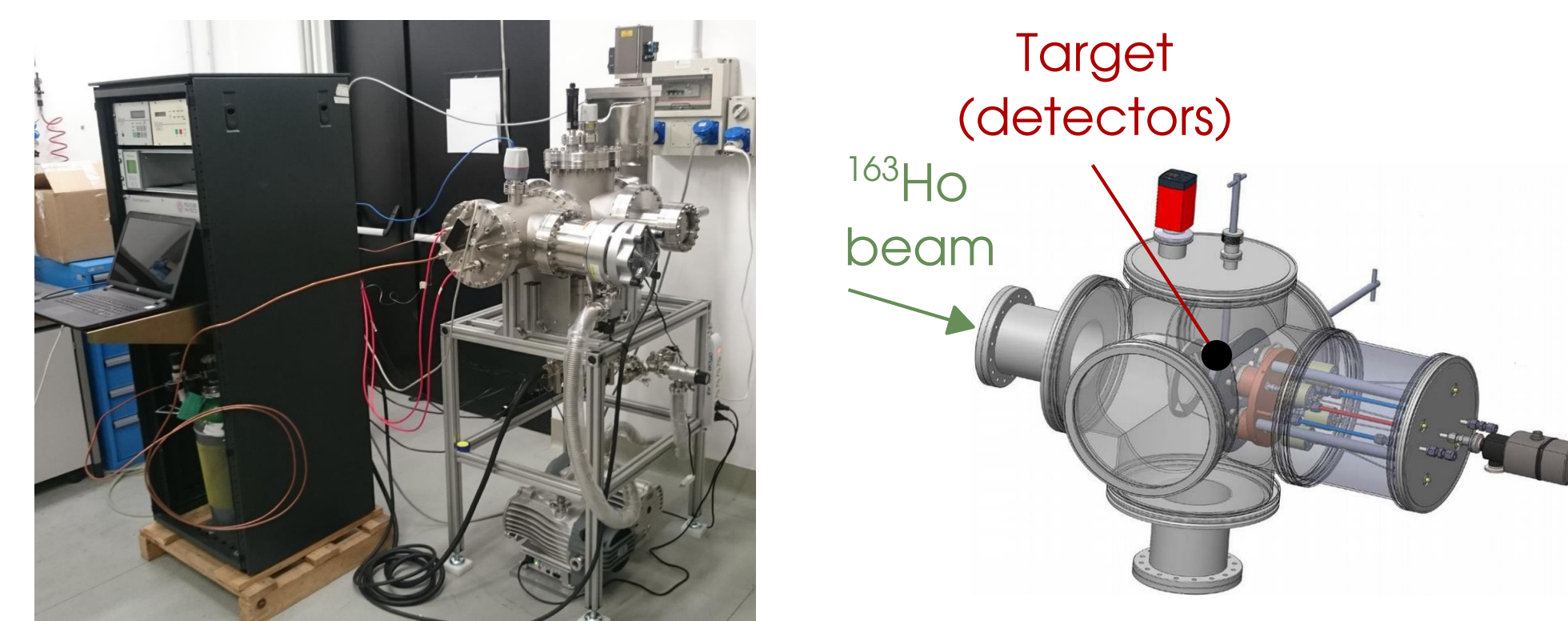
- Irradiation at the ILL reactor in Grenoble with a high thermal flux $\Phi_n = 1.3 \cdot 10^{15} \text{ n/cm}^2/\text{s}$
- Cross section burn up $^{163}\text{Ho}(n, \gamma)^{164}\text{Ho}$ not negligible ($\sim 200 \text{ b}$)
- Unavoidable $^{165}\text{Ho}(n, \gamma)^{166m}\text{Ho}$ (mostly from $^{164}\text{Er}(n, \gamma)^{165}\text{Er}$)
 $\Rightarrow \beta^- : \tau_{1/2} = 1200 \text{ y}, Q = 5.97 \text{ keV}$
 $\Rightarrow A(^{163}\text{Ho})/A(^{166m}\text{Ho}) = (100 - 1000)$
- Chemical pre-purification and post-separation at PSI (based on ion exchange chromatography) leaves a 166:163 ratio better than 1:1000
- Thermoreduction to obtain the metallic Ho target for implantation
 $\text{Ho}_2\text{O}_3 + 2\text{Y}(met) \rightarrow 2\text{Ho}(met) + \text{Y}_2\text{O}_3 @ 2000^\circ\text{C}$

Mass separation based on ion implanter



- Argon penning sputter ion source with an acceleration section allowing to reach a maximum energy of 50 keV
 - Magnetic dipole mass analyzer with magnetic field up to 1.1 Tesla;
 - Focusing electrostatic triplet;
 - Magnetic scanning stage;
 - Deposition and target Chamber
- Currently under commissioning @INFN Genova
- From MC simulations \Rightarrow beam spot $\sim 4 \text{ mm FWHM}$ at the target chamber.
Expected 163/166m separation $\geq 5\sigma$.

Deposition and target Chamber

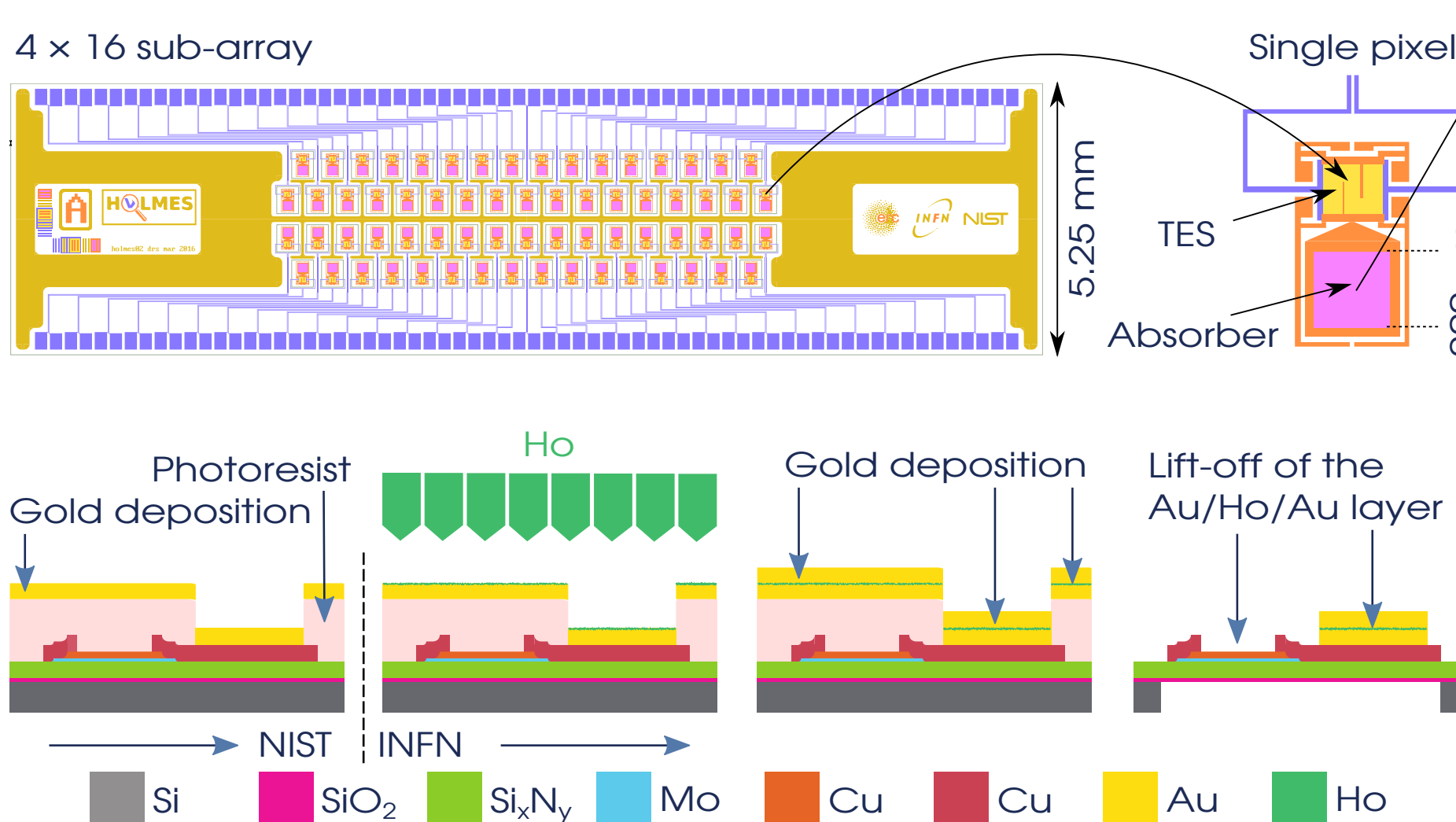


- To obtain $A_{EC} \sim 300$ Bq/det, the ^{163}Ho concentration in absorbers saturate because ^{163}Ho sputters off Au from absorber
 - Effect compensated by Au co-evaporation during the implantation procedure
 - Absorbers finalization with $1 \mu\text{m}$ Au layer deposited in situ to avoid oxidation
 - Au deposition rate $\sim 100 \text{ nm/hour}$ (tunable with RF power or with Ar energy)
- Currently under commissioning @University of Milano-Bicocca

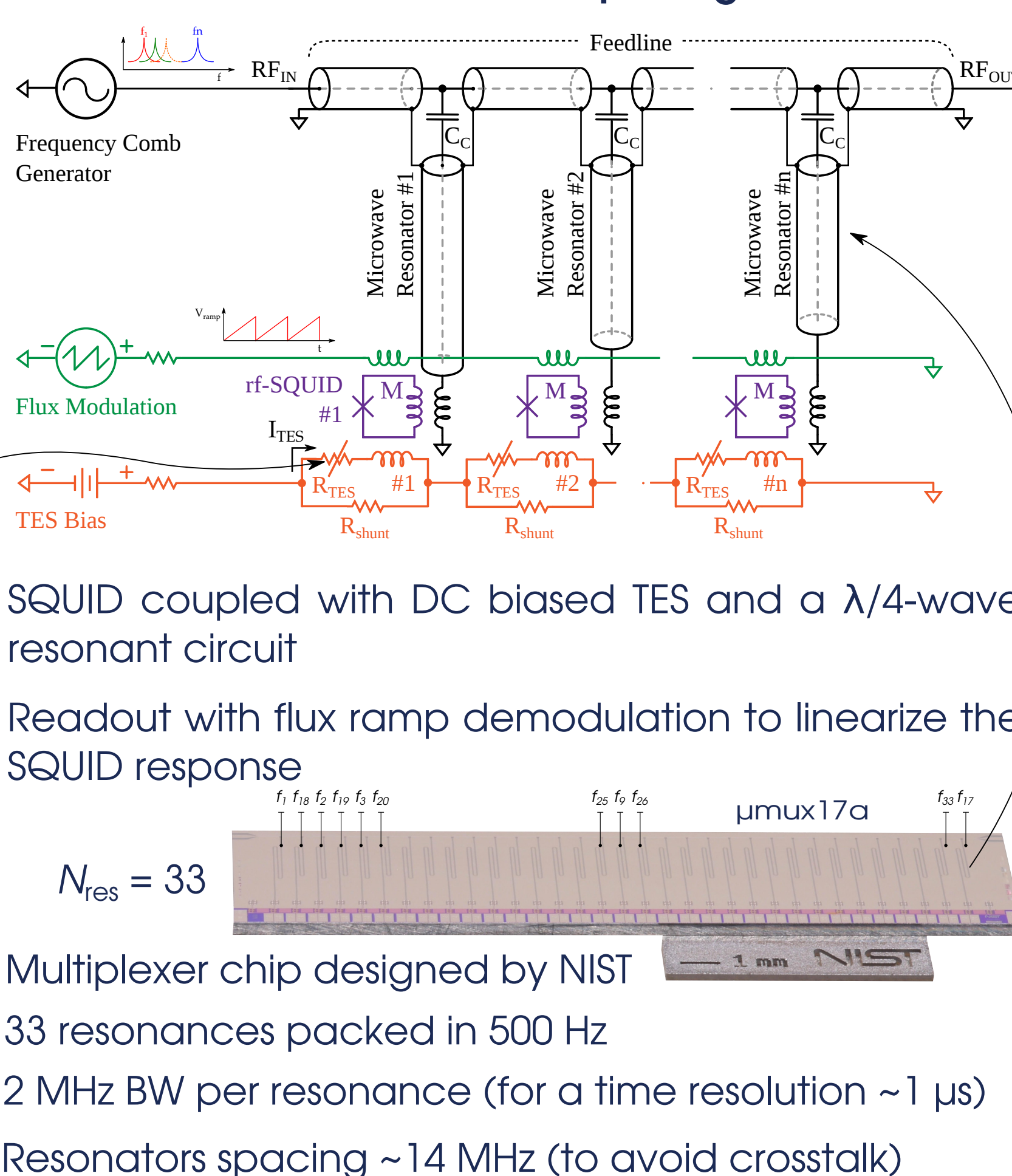
Detectors and Read-out

Low Temperature microcalorimeters

- Sensor: TES Mo/Au bilayers, critical temperature $T_c = 100 \text{ mK}$
- Absorber: Gold, $2 \mu\text{m}$ thick for full e^-/γ absorption (sidecar design)
- Produced @ NIST (Boulder, CO, USA)
- ^{163}Ho implanting and absorber finalization @ INFN-GE (Italy)
- 4×16 linear sub-array designed for high implant efficiency



Microwave rf-SQUID multiplexing read-out



Detector performances

